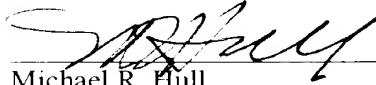




2811
#10
Election
1-16-03
PATENT
29925137672
JAN 14 2003
RECEIVED
TECHNOLOGY CENTER 2800

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Young-Hun Bae and Won-Sung Park)	I hereby certify that this paper and the documents referred to as enclosed therewith are being deposited with the United States Postal Service as first class mail, postage prepaid, on January 9, 2003 , in an envelope addressed to Commissioner for Patents, Washington, D.C. 20231.
Serial No.: 09/940,774)	
Filed: August 27, 2001)	
For: Method for Forming a Gate of a High Integration Semiconductor Device)	
Group Art Unit: 2811)	
Examiner: Donghee Kang)	Michael R. Hull Reg. No. 35,902 Attorney for Applicants

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
Washington, D.C. 20231

Sir:

In response to the restriction requirement imposed in the office action mailed on December 9, 2002, applicants hereby elect Group II, claims 3-5 and 8-10, *with traverse*.

An early office action on the merits of this application is respectfully solicited.

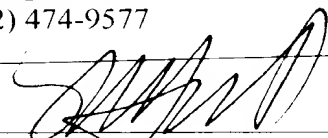
The Commissioner is authorized to charge any fee deficiency required by this paper, or credit any overpayment, to Deposit Account No. 13-2855.

Respectfully submitted,

MARSHALL, GERSTEIN & BORUN
6300 Sears Tower
233 South Wacker Drive
Chicago, Illinois 60606-6357
(312) 474-9577

January 9, 2003

By:


Michael R. Hull
Reg. No. 35,902